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Application Da	ta Sheet 37 CFR	1 76	Attorney Docket N	umber	OGOSH59USA			
Application Bu			Application Number	er				
Title of Invention High Purity Ru Powder, Sputtering Target Obtained by Sintering the Same, Thin Film Obtained by Sputtering the Target and Process for Producing High-Purity Ru Powder								
bibliographic data arrang This document may be	The application data sheet is part of the provisional or nonprovisional application for which it is being submitted. The following form contains the bibliographic data arranged in a format specified by the United States Patent and Trademark Office as outlined in 37 CFR 1.76. This document may be completed electronically and submitted to the Office in electronic format using the Electronic Filing System (EFS) or the document may be printed and included in a paper filed application.							
Secrecy Orde	r 37 CFR 5.2							
					t may fall under a Secrecy Order p er may not be filed electronically.)	ursuant to		
Applicant Info	rmation:							
Applicant 1					Remove			
Applicant Authori	ty • Inventor Le	egal Repre	sentative under 35 l	J.S.C. 11	7 Party of Interest under 35 U	.S.C. 118		
Prefix Given Nan	ne	Mic	dle Name		Family Name	Suffix		
Yuichiro					Shindo			
Residence Inform	ation (Select One)	USF	esidency 💿 No	n US Re	sidency Active US Military Serv	ice		
City Ibaraki		Countr	Of Residencei	JP				
Citizenship under	37 CFR 1.41(b) i	JP						
Mailing Address o	f Applicant:							
Address 1	c/o Isohara Fac	tory of Ni	pon Mining & Metals	Co.				
Address 2	Ltd.,187-4, Usu	ıba, Hana	awa-cho, Kitaibarak	-shi				
City Ibaraki	•		Stat	e/Provii	псе			
Postal Code	319-1535		Country	JP				
Applicant 2			I	1	Remove			
Applicant Authori	ty • Inventor Le	egal Repre	sentative under 35 l	J.S.C. 11	7 Party of Interest under 35 U	.S.C. 118		
Prefix Given Nan		Mic	dle Name		Family Name	Suffix		
Akira					Hisano			
Residence Inform	ation (Select One)	US F	esidency 🌘 No	n US Re	sidency Active US Military Serv	ice		
City Ibaraki		Countr	Of Residence	JP	-			
Citizenship under	Citizenship under 37 CFR 1.41(b) i JP							
Mailing Address o	f Applicant:							
Address 1	c/o Isohara Fac	tory of Ni	pon Mining & Metals	Co.				
Address 2	Address 2 Ltd., 187-4, Usuba, Hanakawa-cho, Kitaibaraki-shi							
City Ibaraki	,		Stat	e/Provii	псе			
Postal Code	319-1535		Country	JP				
All Inventors Must Be Listed - Additional Inventor Information blocks may be generated within this form by selecting the Add button.								
Corresponder	nce Informatio	n:						

An Address is being provided for the correspondence Information of this application.

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Application Data Sheet 37 CFR 1.76		Attorney Docket Number	OGOSH59USA		
		Application Number			
Title of Invention	High Purity Ru Powder, Sputtering Target Obtained by Sintering the Same, Thin Film Obtained by Sputtering the Target and Process for Producing High-Purity Ru Powder				
Customer Numbe	Customer Number 00270				
Email Address wbak@howsonandhowson.com Add Email Remove Email					
Application Information:					

Title of the Invention	High Purity Ru Powder, Sputtering Target Obtained by Sintering the Same, Thin Film Obtained by Sputtering the Target and Process for Producing High-Purity Ru Powder					
Attorney Docket Number	OGOSH59USA		Small Entity Status Claimed			
Application Type	Nonprovisional					
Subject Matter	Utility					
Suggested Class (if any)			Sub Class (if any)			
Suggested Technology C	Suggested Technology Center (if any)					
Total Number of Drawing	wing Sheets (if any) Suggested Figure for Publication (if any)					
Publication Information:						
Request Early Publication (Fee required at time of Request 37 CFR 1.219)						
Request Not to Publish. I hereby request that the attached application not be published under 35 U.S.C. 122(b) and certify that the invention disclosed in the attached application has not been and will not be the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing.						

Representative Information:

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This section allows for the applicant to claim benefit under 35 U.S.C. 119(e), 120, 121, or 365(c). Providing this information in the application data sheet constitutes the specific reference required by 35 U.S.C. 119(e) or 120, and 37 CFR 1.78(a)(2) or CFR 1.78(a) (4), and need not otherwise be made part of the specification.

Prior Application Status	Pending	Remove			
Application Number	Continuity Type	Prior Application Number	Filing Date (YYYY-MM-DD)		
	a 371 of international	PCT/JP2005/001488	2005-02-02		
Additional Domestic Priority Data may be generated within this form by selecting					

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Application Data Sheet 37 CFR 1.76		Attorney Docket Number	OGOSH59USA		
		Application Number			
Title of Invention High Purity Ru Powder, Sputtering Target Obtained by Sintering the Same, Thin Film Obtained by Sputtering the Target and Process for Producing High-Purity Ru Powder					
This section allows for the applicant to claim benefit of foreign priority and to identify any prior foreign application for which priority is					

This section allows for the applicant to claim benefit of foreign priority and to identify any prior foreign application for which priority is not claimed. Providing this information in the application data sheet constitutes the claim for priority as required by 35 U.S.C. 119(b) and 37 CFR 1.55(a).

		Re	move			
Application Number	Country i	Parent Filing Date (YYYY-MM-DD)	Priority Claimed			
2004-056022	JP	2004-03-01	Yes No			
Additional Foreign Priority Data may be generated within this form by selecting the Add button.						

Assignee Information:

Providing this information in the application data sheet does not substitute for compliance with any requirement of part 3 of Title 37 of the CFR to have an assignment recorded in the Office.						
Assignee 1						
If the Assignee is an Organization check here.						
Organization Name	nization Name Nippon Mining & Metals Co., Ltd.					
Mailing Address Informa	tion:					
Address 1	10-1, Toranomon 2-chome, Minato-ku					
Address 2						
City	Tokyo	State/Province				
Country i JP		Postal Code	105-0001			
Phone Number		Fax Number				
Email Address						
Additional Assignee Data may be generated within this form by selecting the Add button.						

Signature:

A signature of the applicant or representative is required in accordance with 37 CFR 1.33 and 10.18. Please see 37 CFR 1.4(d) for the form of the signature.					
Signature	/William Bak/			Date (YYYY-MM-DD)	2006-08-31
First Name	William	Last Name	Bak	Registration Number	37277

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